

	Type	L #	Hits	Search Text	DBs
1	BRS	L1	1137	Zhang-p\$.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
2	BRS	L2	615	ross-b\$.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
3	BRS	L3	2640	air adj3 products adj3 chemicals\$.asn.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
4	BRS	L4	5130	(surfynol\$ or dynol\$ or "SURFYNOL" OR "DYNOL" OR "SURFYNOL.RTM" OR "DYNOL.RTM" OR acetylen\$3 adj3 diol)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
5	BRS	L5	75	(surfynol\$ or dynol\$ or "SURFYNOL" OR "DYNOL" OR "SURFYNOL.RTM" OR "DYNOL.RTM" OR acetylen\$3 adj3 diol) with (semiconductor or wafer or electronic or silicon)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
6	BRS	L6	389008	("134"/\$ or "510"/\$ or "252"/\$ or "438"/\$).ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
7	BRS	L7	20	15 and 16	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
8	BRS	L8	1834	(surfynol\$ or dynol\$ or "SURFYNOL" OR "DYNOL" OR "SURFYNOL.RTM" OR "DYNOL.RTM" OR acetylen\$3 adj3 diol) and (semiconductor or wafer or electronic or silicon)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB

	Type	L #	Hits	Search Text	DBs
9	BRS	L9	223	18 and ("CMP" or chemical adj3 mechanical adj3 (polish\$ or planarization or planariz\$))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
10	BRS	L10	8	19 and (11 or 12 or 13)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB